IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Choi et al.

App. No.:

09/920,341

GPAU:

2877

Filing Date: 08/01/2001

Examiner:

Nguyen, Sang H.

Dkt. No.:

PA17-07V06

Conf. No.:

4146

For:

METHODS FOR HIGH-PRECISION GAP AND ORIENTATION SENSING

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\boxtimes	Form(s)	PTO/SB/08A	and/or	PTO/SB/08B	or	PTO/1449
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to the Examiner's attention in the above-identified application. It is respectfully requested that the cited information be expressly considered during the prosecution of this application, and the references be made of record therein and appear among the "references cited" on any patent to issue therefrom.

FEES DUE

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Ш	within three months of the filing date of a national
	application or within three months of the date of entry
	of the national stage as set forth in § 1.491 in an
	international application. Therefore, no fee is
	believed required.

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Typed Name:

Respectfully Submitted,

Kenneth C. Brooks, Reg. No. 38,393

Legal Department

Molecular Imprints, Inc.

P.O. Box 81536

Austin, TX 78758-1536

(512) 339-7760

(512) 491-8918 (fax)

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Sheet 1 of 3

Complete if Known				
Application Number 09/920,341				
Filing Date	08/01/2001			
First Named Inventor	Choi et al.			
Group Art Unit 2877				
Examiner Name Nguyen, Sang H.				
Attorney Docket Number PA17-07V06				

	U.S. PATENT DOCUMENTS							
Examiner Initials*	Cite No.1	U.S. Patent Doc	ument Kind Code ² (if known)	Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
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	G2	4,208,240		Latos	06-17-1980			
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Examiner Signature			•		Date Considered			

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Sheet 2 of 3

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FOREIGN PATENT DOCUMENTS								
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	G32	wo	00/21689		Chou et al.	04-20-2000		
	G33	wo	01/47003	A2	Steiner et al.	06-28-2001		
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Application Number 09/920,341

Filing Date 08/01/2001

First Named Inventor Choi et al.

Group Art Unit 2877

Examiner Name Nguyen, Sang H.

PA17-07V06

(use as many sheets as necessary)

Sheet 3 of 3

Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s),	T ²
	publisher, city and/or country where published.	
G34	Communication Relating to the Results of the Partial International Search; International Appl. No. PCT/US2002/015551.	
G35	Papirer et al., "The Graftijng of Perfluorinated Silanes onto the Surface of Silica: Characterization by Inverse Gas Chromatography," August 1993, pp238-242, vol. 159, Issue 1.	
G36	Abstract of Papirer et al., "The Graftijng of Perfluorinated Silanes onto the Surface of Silica: Characterization by Inverse Gas Chromatography," August 1993, pp238-242, vol. 159, Issue 1.	
G37	Hirai et al., "Mold Surface Treatment for Imprint Lithography," August 2001, pp 457-462, vol 14, No. 3.	
G38	Abstract of Hirai et al., "Mold Surface Treatment for Imprint Lithography," August 2001, pp 457-462, vol 14, No. 3.	
G39	Sung et al., "Micro/nano-tribological Characteristics of Self-Assembled Monoloayer and its Application in Nano-Structure Fabrication," July 2003, pp. 808-818, vol. 255, no. 7.	
G40	Abstract of Sung et al., "Micro/nano-tribological Characteristics of Self-Assembled Monoloayer and its Application in Nano-Structure Fabrication," July 2003, pp. 808-818, vol. 255, no. 7.	
G41	Roos et al., "Nanoimprint Lithography with a Commerical 4 Inch Bond System for Hot Embossing," October 2001, pp. 427-435, vol. 4343.	
G42	Abstract of Roos et al., "Nanoimprint Lithography with a Commerical 4 Inch Bond System for Hot Embossing," October 2001, pp. 427-435, vol. 4343.	
G43	Office Action for United States Patent Application 10/053,357 dated 12/16/2003	
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